

Laser micromachining capabilities within Scitech Precision and its application toward high power laser experiments

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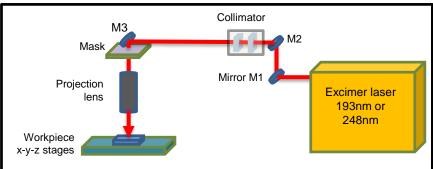
INTRODUCTION

Scitech Precision supports high power laser experiments with the manufacture of high specification laser micromachined targets. Alloys, borosilicate, ceramics, diamond, metals, polymers and single and multilayer thin films can be machined into complex shapes or intricate grids with full characterisation and R&D to support developmental ideas.

Repeatable, consistent targets can be produced using the UV Excimer laser, operating at 193nm or 248nm, the 355nm DPSS (diode pumped solid state) laser, or the infra-red Nd:YAG 1064nm laser.

Excimer machining of multilayer $50\mu m$ cubes

The project involved laser machining cubes from a $50\mu m$ multi-layered coating. The layered samples (7 variants) comprised parylene with embedded chlorinated layers and flash coatings of aluminium and bismuth. Scitech Precision would like to acknowledge AWE TF for characterisation support and sample supply.





Typical laser specification:

60W, 200Hz

17-25ns pulse, 100mJ

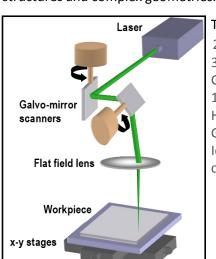
High micron level resolution

Complex mask design

x1 to x30 demag, Lens N.A from 0.15 (at x10 demagnification) Ideal for polymers, ceramics, diamond, sapphire, <100nm metal films

355nm DPSS Nd:YAG MESH MACHINING

Sub mm CAD/CNC based (dxf files) laser micro machining of intricate grid structures and complex geometries.



Typical laser specification: 20W, 200kHz

30ns pulse, 100-500µJ Gaussian beam 18µm focused spot High speed machining

Galvo scanner and/or stages Ideal for metals, diamond, polymers, ceramics, carbon, glasses, thin films



50μm thick silicon 35μm arm width



25μm thick tantalum 25μm arm width

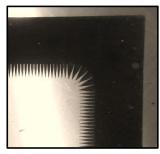


50μm thick niobium 50μm arm width

BEAM STOPS AND APERTURES



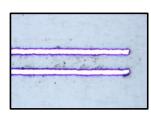
tungsten rod end beam stop 100µm diameter 300µm depth hole



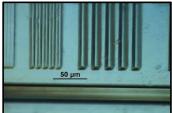
50μm thick tungsten serrated aperture 200μm pitch, 1.2mm height



tungsten Schlieren beam stop 100µm thick 20µm arms



50μm thick tungsten 6μm width slits 20μm gap



25µm PEEK thin sheet laser scribing



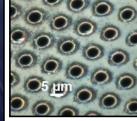
stainless steel 50µm thick 25µm arm width



200μm thick copper 100μm arm width



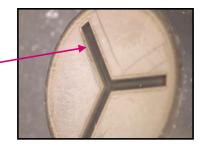
 $200\mu m$ thick tungsten $200\mu m$ arm width Inner circle: ID 170 μm



sapphire 5µm diameter holes



DIAMOND MACHINING
500µm depth, ~1mm width trench











OD 1.3mm